High-Extinction-Ratio and Fabrication-Tolerant Polarization Beam Splitter based on Grating-Assisted Contradirectional Couplers

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Abstract: A fabrication-tolerant polarization beam splitter (PBS) based on grating-assisted contradirectional couplers is experimentally demonstrated. Over 30-dB extinction ratios are achieved for both polarizations. Large fabrication tolerance in coupling length is also verified.

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1. Introduction

Silicon nanowire waveguides with high index-contrast between silicon core and the cladding generally have considerable birefringence values, which result in polarization-dependent dispersions or losses for integrated devices [1]. Polarization beam splitters (PBSs) for splitting two orthogonal polarization modes are key components in polarization-diversity schemes to eliminate the polarization sensitivities [2]. A number of solutions were proposed to realize PBS devices, including multimode interference (MMI) structure [3], directional coupler (DC) [4], photonic crystal [5], hybrid plasmonic waveguide [6], out-of-plane grating [7], and so forth. Polarization extinction ratios (PERs) of previously reported PBSs were below 30 dB except one in [8], which was based on DC. However, optical coupling between the two waveguides in the DC-based PBS was periodically dependent on the coupling length and sensitive to fabrication variations. The PER of the DC-based PBS decreased from 20 dB to 12 dB when coupling length varied from 6.5 μm to 5.5 μm [9]. Recently, a compact PBS based on asymmetrical grating-assisted contradirectional couplers (GACCs) was theoretically proposed [10]. An advantage of such PBS is that it does not require stringent phase matching and coupling length. However, no experimental demonstration of such GACC-based PBS was reported.

In this paper, we experimentally demonstrate the first PBS based on GACCs. The device is fabricated on a silicon-on-insulator (SOI) wafer with a total length of < 30 μm. The coupling of TE mode between the two waveguides is strongly enhanced by GACCs, while the coupling of TM mode does not occur. Optical coupling between the two waveguides is monotonically dependent on the coupling length and insensitive to it. To realize single etch process and simple fabrication, symmetrical vertical structure is used in our design, which differs from that in [10]. The upper cladding of both waveguides is air. The PERs of the fabricated PBS are > 30 dB for both polarizations in a broad wavelength range (~20 nm). If coupling length varies from 27.52 μm to 20.64 μm, the PERs still remain higher than 20 dB for both polarizations. To the best of our knowledge, our device achieves record high PERs with insensitive coupling length on silicon, enabling fabrication-tolerant mass production of the PBS devices.

2. Device design and fabrication

![Fig. 1](https://example.com/fig1.png)

Fig. 1 (a) Schematic structure of the GACC-based PBS. (b)-(c) Simulated power distributions in the GACC-based PBS for TE-polarized and TM-polarized input, respectively.
The GACC-based PBS is schematically illustrated in Fig. 1(a). The device consists of two parallel silicon strip waveguides, A and B. The bent waveguide and S-bend are at Input port and Cross port to make the two waveguides separated, respectively. The corrugations on the sidewall of the two waveguides are designed to form grating structures. The GACC is designed to enhance the coupling of TE mode, but has no effect on the coupling of TM mode. Therefore, TE-polarized light is contra-directionally coupled from waveguide A to waveguide B by the periodic corrugations. High power TE-polarized light is obtained in the Cross port. TM-polarized light goes through waveguide A without coupling. High power TM-polarized light is obtained in the Thru port. Thus, TE- and TM-polarized light are separated by the GACC. It is noted that, the asymmetrical configuration in on-plane direction can suppress the co-directional coupling between the waveguides. Symmetrical structure in normal direction is used in our design to realize single etch process and simple fabrication.

In the PBS structure, the thickness of silicon waveguides is 220 nm. The radius of bent waveguide at the Input port is 18 μm, which is large enough to ensure low-loss for TM-polarized light. The width of the waveguides is \(W_A = 600\) nm and \(W_B = 450\) nm, respectively. The period of the corrugation is \(λ = 344\) nm. The duty cycle of the corrugations is 52%. The corrugation widths are \(ΔW_A = 137\) nm and \(ΔW_B = 123\) nm, respectively. The gap between the waveguides is 65 nm. The offsets for the S-bend are \(L_A = 0.8\) μm and \(L_B = 4\) μm. The coupling length is determined by the period \(λ\) and corrugation period number \(N\). Three-dimensional finite-difference time-domain (3D-FDTD) method is applied to simulate the proposed structure \((N=60)\). The radius of bent waveguide at the Input port is reduced to 5 μm to decrease simulation time in the simulation. The simulated power distributions for the TE- and TM-polarized light inputs are shown in Figs. 1(b) and (c), respectively. If a TE-polarized light is injected into the Input port, the light is contra-directionally coupled to the cross waveguide and outputs from the Cross port. While for a TM-polarized input, the light directly goes through waveguide A and outputs from the Thru port.

In the experiment, the GACC-based PBSs were fabricated on a SOI wafer \((220\text{-nm-thick silicon on 3000-nm-thick silica})\). E-beam lithography (Vistec EBPG 5200) was used to define the structures on the ZEP520A resist. Then the patterns were transferred to the top silicon layer by inductively coupled plasma (ICP) dry etching using \(\text{SF}_6\) and \(\text{C}_2\text{F}_6\) gases. Scanning electron microscope (SEM) images of the fabricated GACC-based PBS with corrugation period number \(N=80\) are shown in Fig. 2.

3. Experiment results

![Fig. 3](image-url) Measured transmission responses at the Cross and Thru ports for (a) TE-polarization and (b) TM-polarization. The corrugation period number \(N\) and coupling length of the fabricated PBS are 80 and 27.52 μm, respectively.

In the measurements, TE- and TM-polarized lights from a tunable laser are coupled into/out of the chip by grating couplers, respectively. The grating couplers have significant polarization dependences. The coupling losses of the TE- and TM-polarized grating couplers are 7.7 dB/port and 8.7 dB/port at the grating central wavelengths,
respectively. Figures 3(a) and (b) show the measured transmission responses at the Cross and Thru ports of the fabricated PBS when TE- and TM-polarized lights are injected, respectively. The corrugation period number \(N\) is 80, and the coupling length is 27.52 \(\mu m\). Two identical PBSs are fabricated to measure responses for TE- and TM-polarized lights inputs, respectively. The responses are normalized by the transmission of a straight waveguide with grating couplers. For the TE-polarized light, the PER is higher than 30 dB in the wavelength range of 1517 nm – 1538 nm, and the insertion loss is < 1 dB. For the TM-polarized light, the PER is higher than 30 dB in the wavelength range of 1510 nm – 1544 nm, and the insertion loss is < 1 dB from 1517 nm to 1544 nm. Some noise observed in Fig. 3 is attributed to that the received power is beyond the detection limit of the optical power meter.

In order to test the fabrication tolerance in coupling length, PBSs with different coupling lengths were fabricated. The measured responses for the fabricated PBSs with coupling lengths of 24.08 \(\mu m\) and 20.64 \(\mu m\) are shown in Figs. 4(a) and (b), respectively. In Fig. 4(a), for the TE-polarized light, the PER is higher than 20 dB in the wavelength range of 1513 nm – 1530 nm, and the insertion loss is < 2 dB. For the TM-polarized light, the PER is higher than 20 dB in the wavelength range of 1510 nm – 1544 nm, and the insertion loss is < 1.5 dB. In Fig. 4(b), for the fabricated PBS with a coupling length of 20.64 \(\mu m\), the PERs still remain higher than 20 dB for both polarizations in the wavelength range of 1515 nm – 1537 nm, and the insertion losses are < 1 dB. These results verify that the presented PBSs have a large fabrication tolerance in coupling length.

![Fig. 4 Measured transmission responses at the Cross and Thru ports for TE- and TM- polarizations of the fabricated PBSs with (a) corrugation period number \(N=70\), coupling length of 24.08 \(\mu m\), (b) corrugation period number \(N=60\), coupling length of 20.64 \(\mu m\).](Tu3E.2.pdf)

### 4. Conclusions

To the best of our knowledge, we have experimentally demonstrated a compact silicon PBS based on GACCs for the first time. The PBSs are realized by single etch process and simple fabrication. The PERs and insertion losses of the fabricated PBSs are > 30 dB and < 1 dB, respectively, for both polarizations in a broad wavelength range of 20 nm. Due to the coupling enhanced by the GACCs, the coupling length does not need rigorous control. With the coupling length varied from 27.52 \(\mu m\) to 20.64 \(\mu m\), the PERs still remain > 20 dB and the insertion losses are < 2 dB for both polarizations. These results show that the PBSs have a large fabrication tolerance in coupling length.

### References